Fast growth of large single-crystalline graphene assisted by sequential double oxygen passivation

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Abstract

Graphene has been considered an extraordinary platform for electronic applications, while it still remains a challenge to fast synthesize large single-crystalline graphene (LSCG) for widespread use. Since the adsorption energy of single carbon on the substrate plays an important role in the nucleation and growth of graphene, we have considered adjusting its adsorption energy to synthesize LSCG. Here, our density functional theory (DFT) calculations expose that oxygen can significantly reduce (~1.03 eV) the adsorption energy of single carbon on oxygen-covered Cu compared with the bare Cu. Motivated by the calculation result that oxygen can induce weaker carbon adsorption energy, the sequential double oxygen passivation method through chemical vapor deposition is proposed to successfully grow the millimeter-scale single-crystalline graphene with the rate of about 100 mm in/C0. This approach could provide a new sight into fast synthesizing LSCG facilely and economically.

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1. Introduction

Graphene is an ideal two-dimensional carbon material [1–4] with the combined properties of excellent mechanical [5,6], electrical [7] and optical properties [8], which has been widely used for various applications [9,10]. Compared to the low yield through mechanical exfoliation [11], graphene synthesized by chemical vapor deposition (CVD) is more effective for industrial-scale production [12], while it is concerning that the traditional CVD-grown graphene on Cu always exhibits a polycrystalline nature with weaker electrical properties [13]. At present, massively synthesis of large single-crystal graphene (LSCG) with the similar excellent properties to the exfoliated graphene [14] is significant for practical applications.

Tremendous efforts have been made to reduce the nucleation density to grow LSCG such as substrate pre-treating [15–18] and gas supply controlling [19–23]. Especially, oxygen introduction is proved effective for assisting LSCG growth, but its role during the synthesis process is still shrouded by mist. Actually, oxygen exhibits a crucial but mysterious role relying on the introducing ways: regarding the short-period oxygen passivation after annealing, the active nucleation sites can be passivated [24], and as for the continuous oxygen supply, hydrocarbon can be faster decomposed by lowering the energy barriers [25]. Moreover, it is reported that oxygen can act as other roles in reducing the nucleation density [26–30].

Beyond the nucleation density reduction, a high growth rate is also essential for massive synthesis [1,2]. The carbon-source supply is an important factor in controlling the growth of LSCG on Cu substrate [31]. Tianru Wu et al. reported the fast growth of inch-sized single-crystalline graphene by locally feeding carbon precursors to a desired position [1]. Subsequently, Zhongfan Liu et al. reported the fast growth of single-crystal graphene on Cu substrate through multistage carbon-source [14]. It is indicated that the carbon-source could play a mutually restricted role in the growth process of graphene: i.e., a lower carbon-source in the nucleation process can reduce the nucleation density, while the higher carbon-source in the growth process can promote the growth kinetics of graphene, which may also induce new nucleation [14,32].

Based on the unique roles of carbon-source supply and oxygen introduction in the reduction of nucleation density and acceleration of growth, a novel oxygen-assisted carbon-source supply
strategy is proposed to fast grow LSCG on the Cu substrate. This strategy adopts a sequential double oxygen passivation method (SDOP): the first oxygen passivation during the nucleation process combined with low carbon supply can help reduce low nucleation density, and the second oxygen passivation combined with high carbon supply can enhance the growth rate.

2. Experiment and calculation

2.1. Growth and characterization of graphene

Large single-crystal graphene was grown using low pressure chemical vapor deposition (LPCVD). Here we apply a CVD system, using a quartz tube as the reaction chamber. Briefly, commercial copper foils (25-μm thick, 99.8%, polycrystalline, Alfa Aesar, #13382) were cleaned using isopropanol, acetone, and CH3COOH. Afterwards, the quartz is used as the base to support the copper, and the copper is bended to wrap the quartz, as shown in Fig. 51a, and then is loaded into the CVD chamber, and placed at the center of the furnace. Then the system was vacuumed to approximately 1 Pa by a mechanical pump for 10 min before the tube was heated of the furnace. Then the system was vacuumed to approximately 2 Pa. The CH4/H2 supply in each process: about 0.1sccm lead to the vacuum of 2 Pa. The CH4/H2 supply ratio in the growth processes is 1:300 while the CH4/H2 supply in the growth process is 1:5. The O2 supply in each process: about 0.1sccm lead to the vacuum of 2 Pa. The CH4/H2 supply ratio in nucleation process is 1:300 while the CH4/H2 supply in the growth process is 1:5. The detailed gas supply, reaction time and temperature can be seen in SI Fig. 2. The individual graphene domain was transferred onto SiO2/Si substrates, using PMMA-assisted wet method for Raman characterization. The individual graphene domain was also transferred to TEM grid for SAED with the help of PMMA and acetone.

The morphology was observed by FESEM (FEI Quanta 200F microscope field emission scanning electron microscope) and TEM (Tecnai G2 F20 Field emission transmission electron microscopy) with accelerating voltage of 200 kV, X-ray electron spectroscopy (XPS) analysis was conducted with a ESCALAB 250Xi X-ray photoelectron spectroscopy equipped with Al Kz radiation, and the binding energy was calibrated by the C1s peak (284.8 eV) of contaminated carbon. Raman spectra was investigated with the electron spectroscope equipped with Al Kz radiation, and the geometry of the system was optimized with the aforementioned sets. The adsorption energies $E_{C-Cu\,ads}$ of per carbon atom here are defined as

$$E_{C-Cu\,ads} = E_{C-Cu\,surface} - E_{Cu\,surface} - E_C$$  \hspace{1cm} (1)$$

where $E_{C-Cu\,surface}$ stands for the energy of a system having a carbon atom adsorbed on the copper surface, $E_{Cu\,surface}$ is the energy of a clear copper surface, and $E_C$ is the energy of an isolated carbon atom under vacuum. With this definition, negative adsorption energies would be obtained, which correspond to the exothermic adsorption process.

The second system imports one layer of oxygen (12 oxygen atoms) on above Cu (111) facet. Then, single carbon atom was adsorbed on the oxygen covered Cu surface, and corresponding adsorption energy $E_{C-oxygen\,covered\,Cu\,ads}$ was calculated with the similar workflow to calculate $E_{C-Cu\,ads}$, as follows:

$$E_{C-oxygen\,covered\,Cu\,ads} = E_{C-oxygen\,-covered\,surface} - E_{oxygen\,-covered\,surface} - E_C$$  \hspace{1cm} (2)$$

where $E_{oxygen\,-covered\,surface}$ is the energy of oxygen covered copper surface, and $E_C$ is the energy of an isolated carbon atom under vacuum.

3. Results and discussion

For hydrocarbon conversion to CVD-grown graphene on Cu, there are three key processes: the catalytic decomposition of hydrocarbon to form active carbon species, graphene nucleation, and the subsequent growth from the nuclei [14,17,33,34]. Many works reported that the adsorption energy of the activated carbon plays an important role in the nucleation and growth processes of graphene [35–37]. As mentioned earlier, the introduction of oxygen plays an important but mysterious role in synthesizing graphene, it is motivating to investigate whether oxygen takes effects resulting from the oxygen-induced change of the adsorption energy. The adsorption energies of the activated carbon on the oxygen adsorbed Cu and the bare Cu have been calculated respectively via density functional theory (DFT). The calculation results expose that oxygen can cause the distinct difference between the adsorption energy of single carbon on the oxygen adsorbed Cu and the bare Cu, as shown in Fig. 1.

The adsorption reaction of the activated carbon on copper (Fig. 1a) can be described as follow:

$$C_{activated\,Cu} = C_{activated\,adsorbed} (-5.17 \text{ eV})$$  \hspace{1cm} (3)$$

whereas the adsorption of the activated carbon on oxygen covered copper (Fig. 1b) through the surface reaction is

$$C_{activated\,oxygen\,-covered\,Cu} = C_{adsorbed\,oxygen\,-covered\,Cu} (-4.14 \text{ eV})$$  \hspace{1cm} (4)$$

Obviously, there is significant carbon adsorption energy reduction (of 1.03 eV). Since the oxygen can induce weak carbon adsorption, and the carbon adsorption energy plays an important role in growing graphene, we have tried to fine control the introduction of oxygen to affect the synthesizing graphene process for fast growing LSCG.

As is discussed before, oxygen can induce the distinct change of the carbon adsorption energy and the adsorption energy strongly affects the nucleation and growth processes of graphene, so it will work if the oxygen is introduced during the nucleation and growth processes. To present a facile way to massively synthesize graphene for practical applications, the introduction of oxygen has been
afforded just via the gas supply in CVD system. Since the carrier gas hydrogen may easily react with the oxygen, the oxygen is introduced earlier and the supply of carbon-source and hydrogen follows in each process. The affective factors in synthesizing graphene have been systematically investigated and after the fine control of the introduction of supply gas, the fast growth of LSCG has been achieved assisted by SODP (see synthesis details in SI Fig. 2).

The oxygen content in the Cu foil samples have been characterized and compared through TOF-SIMS as shown in SI Fig. 3. Similar to the OF-Cu in the TOF-SIMS reported by Hao et al. [24], the oxygen content of our Cu without oxygen passivation drops quickly when the depth varies from 0 to 200 nm. However, different from Cu without oxygen passivation and the reported work [24], the Cu after oxygen passivation shows a smooth decrease during 0–100 nm and then drops until 200 nm. When the depth exceeds 200 nm, the oxygen content in both samples maintains 10–5 at. %.

Furthermore, we have used the XPS to characterize the chemical states of Cu (SI Fig. 4) and O (SI Fig. 5) in the surface of the copper. SI Fig. 4a shows that there only exists one peak at 932.6 eV for samples H-Cu and O-H-Cu, and this peak corresponds to the Cu 2p3/2 peak of Cu [38]. And there are two more peaks at 933.7 eV (CuO) [30], and at 934.7 eV (Cu(OH)2) [38] for samples as-received Cu (SI Fig. 4b) and pretreated Cu (SI Fig. S4c). From Fig. S4, it can be concluded that: there is much Cu(OH)2 and CuO in the native oxide surface of as-received Cu. Even after being pretreated by isopropanol, acetone, and CH3COOH, there still remains high concentration of Cu(OH)2 and CuO. After heating up and annealing under hydrogen, there is only Cu for the sample H-Cu because the Cu(OH)2 and CuO can be reacted with hydrogen and transferred to Cu. After oxygen passivation, there is no obvious difference of XPS Cu 2p for the O-H-Cu compared to H-Cu, indicating that during the oxygen passivation, the reaction of transforming Cu to CuO or Cu(OH)2 doesn’t occur.

Meanwhile, we have investigated the high resolution XPS O1s characterization of these four samples, as shown in SI Fig. 5. Considering that there only exists pure Cu peak in H-Cu and O-H-Cu confirmed by high resolution XPS Cu 2p in SI Fig. 4, the XPS O1s curves of H-Cu and O-H-Cu can be divided into two peaks, 530.7 nm for adsorbed oxygen and 531.5 nm for hydroxyl/carbonate [39]. From SI Fig. 5b and c, it can be concluded that after oxygen passivation, the concentration of adsorbed oxygen (530.7 nm) increases much higher than that of hydroxyl/carbonate (531.5 nm). In addition, in the as-received Cu and pretreated Cu, for one thing, there are CuO and Cu(OH)2 confirmed by high resolution XPS Cu 2p in SI Fig. 4, so there must be the relative oxygen peaks. For another, it’s reported that there exist the surface organic contaminants [40],

Fig. 2. Characterization of synthesized graphene. (a, b) Optical photograph and optical microscopy image of graphene on Cu foil after CVD and oxidation in air. (c) SEM image of graphene (d) Raman spectrum of graphene. Inset: the HRTEM image of graphene. (e) SAED characterization of synthesized graphene to demonstrate the single crystal of graphene. (A colour version of this figure can be viewed online.)
which consist of complicated oxygen peaks. Due to these two points, it is hard to divide the one large peak of CuO and Cu(OH)₂ into specific small peaks.

The synthesized LSCG has been characterized to reveal its properties, as shown in Fig. 2. Fig. 2a shows an optical photograph of synthesized graphene on a Cu foil. This sample was heated in air for 5 min at 200 °C to create a contrast between graphene-covered Cu and bare Cu, enabling us to clarify the size and morphology of graphene. It’s obvious that the synthesized graphene is millimeter-scale (~2 mm), which is consistent with the optical microscopy image of prepared graphene shown in Fig. 2b and the SEM image of graphene in Fig. 2c. More importantly, the Raman spectra of prepared graphene shows that the ratio of 2D peak (2670 cm⁻¹) to G peak (1600 cm⁻¹) is higher than 2, which means that the synthesized graphene is monolayer [16,25], further supported by the HRTEM image of graphene edge (the inset in Fig. 2d). To demonstrate the single-crystal nature of the prepared graphene over millimeter scale, we transferred it to a TEM micro grid, and performed selected area electron diffraction (SAED), as shown in Fig. 2e. Eight different sites were randomly selected in the transferred flake, only a suit of hexagonal diffraction spots with negligible rotation was noticed, indicating that selected area is a single crystalline flake [41,42]. Thus, the fast growth of LSCG can be efficiently achieved assisted by SDOP.

To clarify the mechanism of SDOP on the fast synthesis of LSCG, first oxygen passivation during nucleation and second oxygen passivation growth has been investigated respectively to indicate their effects on synthesizing graphene, as is shown in Fig. 3. Obviously, there are less flakes and larger graphene about 2 mm (Fig. 3a) when O₂ is introduced in these processes, and the growth

![Fig. 3](https://example.com/fig3.png)

**Fig. 3.** Effects of O₂ adsorption during nucleation and growth on the synthesis of graphene. The SEM images of the growth graphene (a) with the O₂ during both nucleation and growth processes (b) without the O₂ during nucleation process, and (c) without the O₂ during growth process. (d, e) The traditional nucleation and growth of graphene. (f, g) Sequential double oxygen passivation (SDOP) assisted nucleation and growth of graphene. (A colour version of this figure can be viewed online.)
rate reaches up to 100 μm min⁻¹.

On the nucleation process, after the first oxygen passivation, the relatively low concentration of CH₄ is introduced to form the nucleation, as illustrated in Fig. 3f. When no oxygen is introduced in the nucleation, the nucleation density (as shown in Fig. 3b) is much higher than that in Fig. 3a, which means that the oxygen can help decrease the nucleation density.

The effects of adsorbed oxygen on controlling the nucleation of graphene are explained by the oxygen induced weak carbon adsorption affecting mechanism. Based on our DFT calculations, there is a significant difference (1.03 eV reduction) between the adsorption energy of single carbon on oxygen adsorbed Cu and bare Cu. The significant adsorption energy reduction can hinder the activated carbon atom to be adsorbed to the oxygen covered copper and thus will help decrease the nucleation density of graphene. This mechanism is consistent with our experimental observation (Fig. 3) that the first oxygen passivation can help control the nucleation density combined with the relatively low supply of carbon source. Thus, the introduced first oxygen passivation in our work can play an active role in controlling the nucleation of graphene for growing LSCG based on the oxygen-induced weak adsorption.

On the growth process, we apply the oxygen to secondly adsorb the surface of Cu before the relatively high concentration of CH₄ is introduced to grow graphene, as illustrated in Fig. 3g. When O₂ is not introduced at this stage, the single-crystal graphene grows to about 0.2 mm (Fig. 3c). But still, in the same reaction time, they are smaller and the nucleation density is higher than graphene (~2 mm) in Fig. 3a. Thus, in addition to decreasing graphene nucleation density, O also affected the graphene growth rate. Importantly, it should be emphasized that since higher concentration of H₂ in the nucleation process may easily react with and eliminate adsorbed oxygen on the copper, it’s necessary to apply the second oxygen passivation to ensure the rich oxygen adsorbed on the copper for oxygen assisted fast growth of LSCG. The growth size of graphene at different times can be seen in SI Fig. 6, which shows that the average growth rate of graphene is about 100 μm min⁻¹.

Since the fast growth of LSCG can be attributed to the highly active carbon flux which can promote the reaction kinetics between the graphene nuclei and the activated carbon [25,43], it is expected that the second oxygen passivation plays an active role in enhancing active carbon supply. To prove this assumption, we have investigated the effects of the adsorption energy on the carbon flux. The adsorption energy can be described as

\[ E_{\text{ads}} = E_{\text{surface}} - E_{\text{surface}} - E_{\text{c}} \]

which is an exothermic reaction process [44,45], so the stronger adsorption energy can lead to more stable adsorption of the activated carbon. Hence, due to the weaker adsorption and its relative reduced energy barrier (1.03 eV) of the carbon on the oxygen-covered Cu according to our DFT calculations, it is much easier for the carbon to desorb and diffuse from the surface of oxygen-covered Cu and thus will greatly increase the flux of active carbon. Therefore, during the growth process, in addition to hindering the new nucleation sites of graphene, oxygen induced weak carbon adsorption can also promote the graphene growth rate.

What’s more, we have investigated the effects of different oxygen pressures on the growth of graphene. From SI Fig. 7, it can be concluded that as the oxygen flow rate increases from 1, 1.5, 2 to 2.5 Pa, the size of the graphene becomes less rectangular and more hexagonal. A little different from the reported works [46–49], the changing law of the growth shape is not really consistent with the reported works as the oxygen flow rate increases. It is assumed that this result can be attributed to the two reasons: firstly, the growth rate of graphene can enhanced due to the effects of oxygen induced low adsorption energy of the single carbon confirmed by our theory calculation and experiments. Secondly, the effects of etching by oxygen as reported by many works. Hence, combined with our DFT calculations and experimental phenomena, it implies that the oxygen induced weak carbon adsorption mechanism can assist in lowering the nucleation density and promoting the growth kinetics. Considering this point with the well-established reported roles of oxygen [24,25], the fast growth of LSCG assisted by SDOP can be explained.

4. Conclusions

In conclusion, we have demonstrated a novel carbon-source supply strategy to fast synthesize LSCG on Cu substrate assisted by SDOP. First oxygen passivation during the nucleation combined with low carbon supply enables the formation of low nucleation density, while the second oxygen passivation during the growth process combined with high carbon supply can greatly enhance the growth rate of the graphene grown on Cu substrate. Basically, the fast growth of LSCG results from the oxygen induced weak carbon absorption and its cooperative effects of low nuclear density and fast growth rate. With the assistance of SDOP, the millimeter-scale single-crystalline graphene grows at a speed up to 100 μm min⁻¹. This approach could be helpful in promoting the development of synthesizing LSCG more facilely and economically.

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Appendix A. Supplementary data

Supplementary data related to this article can be found at http://dx.doi.org/10.1016/j.carbon.2017.01.108.

References
